# Enhanced Microstrip Filter Design With a Uniform Dielectric Overlay for Suppressing the Second Harmonic Response

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Abstract—Parallel-coupled microstrip filters are designed to suppress spurious response at twice the passband frequency  $(2f_o)$ with a uniform dielectric overlay. The overlay dielectric is used to equalize the modal phase velocities of each coupled stage. Based on the method, we have a large degree of freedom in choosing thickness and permittivity of the overlay dielectric. The image impedances of all the coupled stages in such a filter need adjusting to complete the filter synthesis. Two filters are fabricated and measured results show a good agreement with the simulation. A suppression of at least 40 dB to the spurious responses at  $2f_o$  is achieved.

*Index Terms*—Microstrip filter, overlay dielectric, phase velocity equalization, spurious response.

#### I. INTRODUCTION

**H** IGH-PERFORMANCE bandpass filters are usually required in the RF front end of a wireless communication system. One of the most common methods for implementing a planar filter is to use parallel-coupled microstrip filters [1], [2]. The traditional design of parallel-coupled line filters, however, suffers from the spurious response at twice the design frequency  $(2f_o)$  [2]–[6], which not only degrades passband symmetry but also deteriorates rejection levels in upper stopband. It is due to that phase constants of the even  $(\beta_e)$  and odd  $(\beta_o)$  modes of each coupled stage are not identical.

It has been shown that a microstrip coupler with  $\beta_e = \beta_o$  will have more bandwidth and better isolation characteristic. The equalization of  $\beta_e$  and  $\beta_o$  can be achieved by using capacitor compensation [3], suspended substrates [4], corrugated coupled lines [5] and an overlay dielectric [6].

In this letter, we design a bandpass filter with suppression of spurious responses at  $2f_o$  by using a flat dielectric overlay. For a single-stage coupler with an overlay, the thickness of the overlay dielectric can be easily determined by a full-wave transmission line program, e.g., the spectral domain approach [7]. The thickness of the overlay dielectric, however, generally depends on material constants and geometric dimensions of the

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 $\begin{array}{c|c} Air \\ h_2 & \mathcal{E}_{r_2} & WS & W \\ \hline h_1 & \mathcal{E}_{r_1} \end{array}$ 

Fig. 1. Coupled microstrips with an overlay dielectric.



Fig. 2. Required  $h_2/h_1$  ratios for making  $\beta_e = \beta_o$  at  $2f_o = 4.9$  GHz.  $\varepsilon_{r_1} = \varepsilon_{r_2} = 10.2, h_1 = 1.27$  mm.

coupled microstrips. A multiorder filter consists of a cascade of several coupled stages. If the overlay dielectrics for these stages have different dimensions, fabrication of the whole filter will be tedious and difficult. Our objective is thus to design a filter with a uniform overlay dielectric, so that each stage has  $\beta_e = \beta_o$ , for suppressing the spurious responses.

In the following, Section II describes the design procedure, Section III compares the responses of two fabricated bandpass filters with those obtained by traditional design, and Section IV draws the conclusion.

### **II. ENHANCED DESIGN**

The design procedure is similar to that in [4] where a parallel-coupled line filter is designed on a suspended substrate with a uniform suspension height. Suppose we are designing a filter with  $f_o = 2.45$  GHz. First, referring to the multilayered coupled lines in Fig. 1, use a full-wave program to find a proper  $h_2/h_1$  ratio for given values of  $W/h_1$  and  $S/h_1$  to have  $\beta_e = \beta_o$ at  $2f_o = 4.9$  GHz. Our numerical experiences show that  $\varepsilon_{r_2}$ must be no less than  $\varepsilon_{r_1}$  for the equalization of  $\beta_e$  and  $\beta_o$ . For convenience, choose  $\varepsilon_{r_2} = \varepsilon_{r_1}$  herein. Fig. 2 plots the required

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Fig. 3. Even- and odd-mode characteristic impedance design data for coupled microstrips with an overlay dielectric.  $\varepsilon_{r_1} = \varepsilon_{r_2} = 10.2$ ,  $h_1 = 1.27$  mm. PVEC represents the phase velocity equalization curve with  $h_2/h_1 = 0.2$ .

 $h_2/h_1$  for coupled microstrips in such a structure. It can be seen that  $h_2/h_1$  is increased when  $W/h_1$  or  $S/h_1$  is increased. These curves indicate possible choices of geometric dimensions of the coupled lines in the design. For example, if  $h_2/h_1 = 0.4$  is used, the range of  $W/h_1$  is from 0.15 to 1.4 when  $0.1 \le S/h_1 \le 2.0$ . It is worth mentioning that when  $\varepsilon_{r_2}$  is changed, the required thickness ratio  $h_2/h_1$  must be calculated again.

Then, we can choose a suitable  $h_2$  value, e.g.,  $h_2/h_1 = 0.2$ , for circuit realization. The even- and odd-mode characteristic impedance design data at 2.45 GHz for the multi-layer structure can be established as in Fig. 3. In addition, a phase velocity equalization curve (PVEC) can be plotted together with the design data. The curve connects all intersection points of a horizontal line  $h_2/h_1 = 0.2$  and the curves in Fig. 2. On the PVEC, all the coupled lines have the same dielectric overlay, and their respective  $\beta_e$  and  $\beta_o$  are identical. Note that the even- and odd-mode characteristic impedances of the coupled microstrips for each point on the PVEC should be calculated at 2.45 GHz.

Finally, apply the synthesis method for parallel-coupled line filters developed in [4] to determine the image impedance of each stage. The method requires three to five iterations to obtain the final results for a fifth-order filter. The reference port impedance can also be a variable in the iteration. When it is not 50  $\Omega$ , tapped input/output couplings [8] can be employed to avoid the use of impedance transformers.

#### **III. MEASURED RESULTS**

We use the full-wave ANSOFT HFSS finite element software for simulation before the circuits are fabricated. Fig. 4 plots the simulation and measured  $|S_{11}|$  and  $|S_{21}|$  responses for a third-order Chebyshev filter with a fractional bandwidth  $\Delta = 10\%$ . It has four coupled stages, and two pairs of variables  $(W/h_1, S/h_1)$  on the PVEC have to be determined by the iteration. The results are (0.501, 0.299) and (0.135, 1.254) for the first and the second stages, respectively. The total length of the filter is 4.09 cm. The measured results agree with the simulation quite well. The responses for a parallel-coupled line filter, based on the traditional design [1], on a substrate with  $\varepsilon_r = 10.2$  are also plotted for comparison. The measured data show that the



Fig. 4. Simulated and measured  $|S_{11}|$  and  $|S_{21}|$  responses of a third-order Chebyshev filter. The center frequency  $f_o = 2.45$  GHz. Material constants see Fig. 3.



Fig. 5. Simulated and measured responses of a fifth-order Chebyshev filter. The center frequency  $f_o = 2.45$  GHz. (a)  $|S_{11}|$  and  $|S_{21}|$  responses. (b) Photo of the circuit. Above the filter is the overlay dielectric.

insertion loss at the design frequency is less than 0.7 dB, and that a suppression of more than 40 dB to the spurious response at  $2f_o$  is obtained.

Fig. 5(a) shows the results of a fifth-order Chebyshev filter with  $\Delta = 10\%$  built on the same structure as that in Fig. 4. The first coupled stage has  $(W/h_1, S/h_1) = (0.486, 0.315)$ , the second (0.124, 1.351), and the third (0.103, 1.573). In measured results, the insertion loss at 2.45 GHz is 1.7 dB and the return loss is better than 15 dB. Both the simulation and measured  $|S_{21}|$  responses have a dip at around  $2f_o$ . This indicates that the even- and odd-mode phase velocities of each coupled stages coincide very well. Again, comparing with the traditional design, we achieve a suppression of at least 40 dB to the spurious response at  $2f_o$ . Fig. 5(b) is the photo of the circuit.

## **IV. CONCLUSION**

Parallel-coupled microstrip filters are design with a uniform layer of dielectric overlay to suppress the spurious response at twice the design frequency. Based on our method, the thickness and  $\varepsilon_r$  of the dielectric overlay can have a large degree of freedom to choose. The results of the third- and fifth-order filters show that a suppression of more than 40 dB is obtained.

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